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19. (Amended) A film manufacturing method characterized in that a composition according to claim 1 is supplied and distributed on a substrate, and thereafter, this substrate is subjected to heat treatment.

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22. (Amended) The film manufacturing method according to claim 20 wherein, after high temperature processing, pressure is immediately reduced as-is, and solvent is removed.

23. (Amended) The film manufacturing method according to claim 20 wherein said dispensing apparatus is an ink jet printing apparatus.

24. (Amended) A functional device characterized by being formed using a composition disclosed in claim 1.

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28. (Amended) The functional device according to claim 25 wherein said display device is an organic EL device.

32. (Amended) The functional device manufacturing method according to claim 30 wherein said heat treatment is performed under applying pressure.

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33. (Amended) The functional device manufacturing method according to claim 30 wherein, during said heat treatment, pressure is reduced prior to a composition becoming completely dry.

34. (Amended) The functional device manufacturing method according to claim 29 wherein a hole injection/transport layer is formed by an ink jet method on said substrate having a first electrode using a solution comprising a polar solvent, and thereafter, said luminescent material layer pattern is formed on the hole injection/transport layer, whereby an organic EL device is obtained.

35. (Amended) The functional device manufacturing method according to claim 29 wherein an organic EL device is obtained as said functional device.